

# PROCEEDINGS OF SPIE

## ***Nanophotonics and Micro/Nano Optics IX***

**Zhiping Zhou**  
**Kazumi Wada**  
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*Editors*

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# Contents

vii *Symposium Committees*  
xi *Conference Committee*

---

**SESSION 1 METASURFACES I**

---

- 12773 04 **Cavity-coupled narrow bandwidth Fano resonance in dielectric metasurface** [12773-3]
- 12773 05 **Narrow-linewidth circular dichroism in asymmetric double split ring resonator metasurface** [12773-6]
- 12773 06 **Application of PT-symmetry in metasurfaces for measuring the inclination angle** [12773-7]

---

**SESSION 2 METASURFACES II**

---

- 12773 07 **Prototype of a metasurface scale for an optical rotation angle sensor** [12773-8]
- 12773 08 **Polarization-sensitive optical absorption modulation driven by toroidal-dipole resonance in asymmetric dielectric tetramer metasurface** [12773-9]
- 12773 09 **Tunable coupling between molecular vibration and sub-radiant magnetic quadrupole in a plasmonic metasurface** [12773-10]
- 12773 0B **Chiral metasurface sensing performance analysis based on bound states in the continuum** [12773-12]

---

**SESSION 3 METASURFACES III**

---

- 12773 0F **Metasurface-integrated microring resonators for off-chip vortex beam generation** [12773-18]

---

**SESSION 4 PLASMONICS**

---

- 12773 0G **Modelling of all optical synchronous up-counter using microring resonator** [12773-19]

---

**SESSION 5 LASER OPTICS**

---

- 12773 OJ **Femtosecond-laser nanostructuring of silicon thin films for optical information encryption** [12773-24]
- 12773 OK **Multifunctional superhydrophobic platform for control of water microdroplets by non-uniform electrostatic field** [12773-25]
- 12773 OL **Internal structure and quantum efficiency of hybrid metal-dielectric nanoparticles fabricated by femtosecond laser exposure of bi-layer film** [12773-26]

---

**SESSION 6 OPTICAL MICRORESONATORS**

---

- 12773 OM **Fabrication of the SNAP microresonator devices by high-ohmic wire heating** [12773-27]
- 12773 ON **Changes of the SNAP resonator shape owing to mode energy dissipation** [12773-28]
- 12773 OO **Thermal mode decomposition method for microresonator thermal parameters estimation** [12773-29]
- 12773 OP **Low threshold Brillouin lasing with hybrid modes of coupled silica microtoroids** [12773-30]

---

**SESSION 7 NONLINEAR OPTICS**

---

- 12773 OR **Metal-organic frameworks as competitive non-linear optical materials: light conversion and structural modification** [12773-33]

---

**SESSION 8 OPTICAL SENSORS**

---

- 12773 OT **Parity-time symmetry mode of coupled subwavelength silicon rectangular gratings** [12773-36]
- 12773 OU **SERS mapping of Mycobacterium tuberculosis single-cell with different drug resistance** [12773-37]

---

**SESSION 9 INTEGRATED OPTICS**

---

- 12773 OW **Gallium phosphide nanoantenna controls enhanced single-molecule fluorescence** [12773-41]

---

**POSTER SESSION**

---

- 12773 0X **Nano mode converter using dynamic refractive index modulation** [12773-32]
- 12773 0Z **A transparent and flexible MXene/Ni mesh composite film for electromagnetic interference shielding** [12773-42]
- 12773 10 **3D memory-reduced form of the one-step leapfrog ADI-FDTD method based on the electromagnetic divergence relationship** [12773-43]
- 12773 11 **Optical manipulation based on tightly focused high-order axially symmetric polarized beams** [12773-44]
- 12773 15 **Enhancement of intrinsic chirality based on asymmetric metasurface** [12773-48]
- 12773 16 **A novel FDFD method for electromagnetic simulation based on adaptive grids** [12773-49]
- 12773 17 **Chiroptical properties in rotated nanohole arrays** [12773-51]
- 12773 19 **Plasmonic hydrogen sensor based on Pd-Ag synergistic multilayer composite film array** [12773-53]
- 12773 1A **Non-volatile and reconfigurable on-chip optical digital neural network based on Sb<sub>2</sub>Se<sub>3</sub>-assisted phase shifters** [12773-54]
- 12773 1B **Chiral metasurface sensors based on bound states in the continuum** [12773-56]

---

**DIGITAL POSTER SESSION**

---

- 12773 1F **Deep-learning based design and modeling for chiro-optical dielectric metasurfaces** [12773-4]
- 12773 1G **An overview of deep-learning models for metasurface design and optimization** [12773-5]
- 12773 1H **Broadband multifunctional achromatic metalens** [12773-14]
- 12773 1I **Multi-band perfect vortex beam generation using all-dielectric metasurface** [12773-15]
- 12773 1J **Theoretical analysis of optical Tamm mode excitation using dielectric nanoparticles** [12773-35]
- 12773 1K **Fluid-infiltrated on-axis ultra-compact reconfigurable intelligent surface for application of free-space optical communication** [12773-39]
- 12773 1L **Off-axis spectral resolution via all-dielectric dispersive metadvice** [12773-60]



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